# Ballistic electron channels including weakly protected topological states in delaminated bilayer graphene

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(Received 11 October 2017; published 11 January 2018)

We show that delaminations in bilayer graphene (BLG) with electrostatically induced interlayer symmetry can provide one with ballistic channels for electrons with energies inside the electrostatically induced BLG gap. These channels are formed by a combination of valley-polarized evanescent states propagating along the delamination edges (which persist in the presence of a strong magnetic field) and standing waves bouncing between them inside the delaminated region (in a strong magnetic field, these transform into Landau levels in the monolayers). For inverted stackings in BLGs on the left and right of the delamination (AB-2ML-BA or BA-2ML-AB, where 2ML indicates two decoupled monolayers of graphene), the lowest-energy ballistic channels are gapless, have linear dispersion, and appear to be weakly topologically protected. When BLG stackings on both sides of the delamination are the same (AB-2ML-AB or BA-2ML-BA), the lowest-energy ballistic channels are gapped, with a gap  $\varepsilon_g$  scaling as  $\varepsilon_g \propto W^{-1}$  with delamination width and  $\varepsilon_g \propto \delta^{-1}$  with the on-layer energy difference in the delaminated part of the structure. Depending on the width, delaminations may also support several "higher-energy" waveguide modes. Our results are based on both the analytical study of the wave matching of Dirac states and tight-binding model calculations, and we analyze in detail the dependence of the delamination spectrum on the electrostatic conditions in the structure, such as the vertical displacement field.

### DOI: 10.1103/PhysRevB.97.045301

### I. INTRODUCTION

Demand for increasingly dense computational architectures is driving the miniaturization of conventional electronic circuits to their limit, requiring novel technologies to be developed. Single-layer graphene, with its gapless band structure, high-mobility carriers, and high thermal conductivity [1], has been considered as a candidate for the creation of conducting nanochannels. However, lithographic processes used for the patterning of such wires spoil graphene edges, introducing defects which make fabrication of ballistic channels in graphene a technological challenge. At the same time, the use of a split-gated structure on monolayer graphene does not help to confine electrons due to high transparency of p-n interfaces [2].

An alternative approach to creating ballistic "onedimensional" channels in graphene is to use a gate-controlled gap in its Bernal (AB) stacked bilayer allotrope, which has an electrostatically tunable band gap [3–7]. Earlier studies [8–12] have shown that sharply switching the direction of the vertical displacement field across these split-gated structures leads to ballistic "topological" modes localized near the boundaries, persisting across junctions of interfaces [13,14]. It has also been found that delaminations of bilayer graphene (BLG) can provide well-defined one-dimensional channels [15,16] with counterpropagating modes in the opposite valleys ( $K^+$  and  $K^-$ ). Experimental observations of states along delaminations naturally occurring in mechanically exfoliated graphene have already been reported [17,18].

In this paper, we study electronic properties of delaminations in a BLG sheet and their dependence on the electrostatically controlled displacement field applied to the structure. Such a system, modeled by both four-band  $\vec{k} \cdot \vec{p}$  theory of BLG and the numerical tight-binding (TB) model approach, is illustrated in Fig. 1. The delamination is considered to be two decoupled monolayers of graphene (2ML) between two BLG regions either in the same (AB-2ML-AB or BA-2ML-BA) stacking configuration or with opposite (AB-2ML-BA or BA-2ML-AB) stacking. The vertical displacement field  $E_{\tau}$  (in real devices, controlled by top and bottom gates) induces a band gap in the BLG,  $\Delta = eE_zd$ , and also mutually shifts on-site energies on the two delaminated monolayers by  $\delta = eE_zd'$ .

The low-energy band structure of Bernal stacked (AB or BA) BLG is described by a four-band  $\vec{k} \cdot \vec{p}$  Hamiltonian [4,7] and band dispersion,

$$E^{\text{BLG}} = \pm \sqrt{v^2 (k_x^2 - k_y^2) + \frac{\Delta^2}{4} + \frac{\gamma_1^2}{2} + r \sqrt{\frac{\gamma_1^4}{4} + v^2 (k_x^2 + k_y^2) (\gamma_1^2 + \Delta^2)}}.$$
(1)

Here,  $r = \pm$  indexes the low- and high-energy BLG bands,  $\Delta$ is the interlayer asymmetry gap,  $k_{x,y}$  are the in-plane wave vectors of electrons in  $K^{\pm}$  valleys, and  $\gamma_1 = 0.39$  eV and v = 6.6 eV Å are the interlayer coupling and Dirac velocity, respectively [19]. This BLG spectrum suggests that at the energies  $|\varepsilon| < \varepsilon_*$ ,

$$\varepsilon_* = \frac{\gamma_1 |\Delta|}{2\sqrt{\Delta^2 + \gamma_1^2}},\tag{2}$$

there are no states for electrons in a gapped bilayer.

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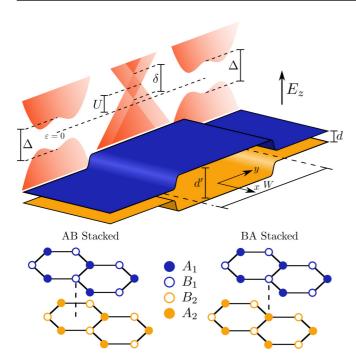


FIG. 1. Sketch of the considered delamination. The decoupled monolayers lie in the region 0 < y < W, connected to two bilayer graphene regions  $(y \le 0 \text{ and } y \ge W)$ . Corresponding energy dispersions within each distinct zone are shown with the electrostatic variables of the model indicated. These would be tuned by varying the vertical displacement field  $E_z$  across the system via top and bottom gates in each region. Below are images depicting the two different Bernal stacking arrangements discussed in the text.

In contrast, the electron spectrum in the delaminated region is gapless (see Fig. 1),

$$E^{2\text{ML}} = U + l\frac{\delta}{2} \pm v\sqrt{k_x^2 - k_y^2}.$$
 (3)

Here, U is an energy shift between the BLG and 2ML regions,  $l=\pm$  are upper (+) and lower (-) monolayer indexes, and  $\delta$  is the energy offset between them produced by the displacement field (in principle,  $\delta=eE_zd'$  can be larger than the BLG gap  $\Delta$  due to the larger interlayer distance within the delamination, d'>d). Due to its continuous spectrum, the delamination can support states within the BLG gap, and in the following, we will analyze the dispersion of electrons channeled by the delamination.

In particular, in Sec. II we analyze a system with a single interface between bias-gapped BLG and 2ML, which supports valley-polarized evanescent modes with linear dispersion. In Sec. III, we study evanescent edge states and standing waves inside a delamination using both the continuum  $\vec{k} \cdot \vec{p}$  model and TB calculations. The form of these states depends on the choice of interlayer stacking on either side of the decoupled monolayers. Inequivalent BLG stacking on either side of the delamination (AB on one side and BA on the other) results in the valley-polarized channels propagating in the same direction along both interfaces, leading to a gapless dispersion with two weakly topologically protected modes with dispersion spanning across the BLG gap. Having the same stacking in the outer BLG parts of the structure reverses the direction of one of these channels, so that the resulting counterpropagating evanescent modes hybridize, producing a gapped spectrum. We also analyze the higher-energy "gapped" modes resulting from standing waves bouncing between the gapped BLG regions, and we study the dependence of the spectrum on the displacement-field-shifted energies of Dirac points in the delaminated layers. In Sec. IV, we study how a strong magnetic field transforms the modes in the AB-2ML-BA structure into Landau levels in the delaminated monolayers.

Before going into the technical details of Secs. II–IV, we note that edges in graphene flakes can take two different forms: zigzag and armchair [20,21]. For the armchair edge, electron scattering from it mixes electron states in the two valleys. In contrast, for a zigzag edge or an arbitrarily cut edge, the large momentum difference between  $K^+$  and  $K^-$  projections onto the delamination axis suppresses intervalley mixing [20]. For this study, we assume general boundary conditions that coincide with those of a zigzag edge but will underline features of the armchair edge in Sec. V.

# II. ELECTRONIC PROPERTIES OF A SINGLE BLG-2ML INTERFACE

To study a single BLG-2ML interface using  $\vec{k} \cdot \vec{p}$  theory, we employ a four-band Hamiltonian,

$$\hat{\mathcal{H}}_{\eta} = \begin{pmatrix} V_{+}(y) & v\hat{\pi}^{\dagger} & \Theta(-y)\gamma_{1} & 0\\ v\hat{\pi} & V_{+}(y) & 0 & w_{3}^{\dagger}\\ \Theta(-y)\gamma_{1} & 0 & V_{-}(y) & v\hat{\pi}\\ 0 & w_{3} & v\hat{\pi}^{\dagger} & V_{-}(y) \end{pmatrix}, \quad (4a)$$

written in the sublattice basis  $(A_1,B_1,B_2,A_2)^T$  in valley  $K^\eta$ , where  $\eta=\pm$ ,  $\hat{\pi}=\eta(-i\partial_x)+i(-i\partial_y)$ , and  $\{\Theta(-y),\hat{\pi}\}$  in  $w_3=\frac{v\gamma_3}{2\gamma_0}e^{i\theta}\{\Theta(-y),\hat{\pi}\}$  is an anticommutator. In this Hamiltonian, hopping parameter  $\gamma_1$  describes coupling of the "dimer" sites,  $A_1$  and  $B_2$ , of the bilayer, whilst terms with  $\gamma_3$  describe skew hopping (between nondimer sites),  $^1$  and angle  $\theta$  is between the zig-zag direction and delamination axis. On-site energies,  $V_\pm(y)$ , are defined as,

$$V_{\pm}(y) = \begin{cases} \pm \frac{\Delta}{2}, & y \leqslant 0, \\ U \pm \frac{\delta}{2}, & y > 0, \end{cases}$$

and  $\Theta(y)$  is the Heaviside step function used to implement the suppression of  $\gamma_1$  by delamination. This Hamiltonian has the dispersion of Eqs. (1) and (3) in regions  $y \leq 0$  and y > 0, respectively. Implicit within this Hamiltonian is the required continuity of the electron wave functions at the junction between the two regions,

$$\begin{pmatrix} 1 & 0 & 0 & -\aleph \\ 0 & 1 & 0 & 0 \\ 0 & -\aleph & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \psi(y \to 0^{-}) = \psi(y \to 0^{+}). \tag{4b}$$

<sup>1</sup>In contrast to the vertical interlayer hopping,  $\gamma_1$ , for electrons at the  $K^+$  and  $K^-$  points in a pristine graphene bilayer the effect of skew interlayer hopping,  $\gamma_3$ , cancels out as we sum the phase contributions from the three nearest interlayer neighbours. At the delamination such cancellation is broken, which leads to the off-diagonal terms in boundary condition (4b). However, the quantitative effect of such a term is negligibly small.

Parameter  $\aleph = e^{i\theta} \gamma_3/(2\gamma_0)$  is determined by the ratio of the skew interlayer hopping [3] and intralayer hopping. As  $\gamma_3/\gamma_0 \approx 0.12$  (hence,  $\aleph \ll 1$ ), the skew hopping ( $\gamma_3$ ) terms lead to only small corrections to the interface mode dispersion and wavefunctions (see Fig. 3). Therefore, the terms describing skew hopping will be neglected in the rest of the text (formally, setting  $\gamma_3/\gamma_0 \to 0$ ).

# A. Reflection at the BLG-2ML interface

Here, we investigate the reflection of plane waves in a semi-infinite delamination and their scattering between two monolayers from a gapped BLG. On the delaminated side of the interface we solve the Dirac equation,

$$(\hat{\mathcal{H}}_n - \varepsilon \hat{I})\psi = 0,$$

assuming propagating plane-wave solutions,

$$\Psi^{\text{2ML}} = \psi^{\text{2ML}} e^{ik_x x} \propto e^{i(q_{s,l})y} e^{ik_x x}, \quad q_{s,l} = s \frac{1}{v} \sqrt{\left(\varepsilon - U - l \frac{\delta}{2}\right)^2 - v^2 k_x^2}, \tag{5}$$

where  $q_{s,l}$  have real values. Here,  $s=\pm 1$  and  $l=\pm 1$  distinguish between right- and left-moving waves (y>0) and the upper and lower layers, respectively:

$$\psi^{2\text{ML}}(k_{x},\varepsilon) = \sum_{s} \left[ A_{s,+} \begin{pmatrix} 1 \\ a_{s,+} \\ 0 \\ 0 \end{pmatrix} e^{iq_{s,+}y} + A_{s,-} \begin{pmatrix} 0 \\ 0 \\ 1 \\ a_{s,-} \end{pmatrix} e^{iq_{s,-}y} \right], \tag{6}$$

where  $A_{s,\pm}$  are the monolayer wave amplitudes and

$$a_{s,l} = \frac{2v[k_x + ilq_{s,l}]}{2\varepsilon - 2U - l\delta} \tag{7}$$

are chirality factors for electrons in monolayer graphene.

Because the direction of the electron's propagation is given by group velocity,  $\bar{v} = \partial \varepsilon / \partial k$ , electrons in the monolayer conduction band with wave vector  $\vec{k}$  move in the direction opposite those in the monolayer valence band with the same wave vector. In order to distinguish between left- and right-moving states we write the index  $s = \pm \xi_l$ , where  $\xi_l = \text{sgn}(\varepsilon - [U + l\delta/2])$  determines whether electrons lie in the conduction ( $\xi_l = +$ ) or valence ( $\xi_l = -$ ) band in each monolayer and the  $\pm$  selects left- (-) or right-(+) moving states.

At the same time, the asymptotics of eigenstates in the gapped bilayer region must be decaying,

$$\Psi_{(y\leqslant 0)}^{\mathrm{BLG}} = \psi^{\mathrm{BLG}} e^{ik_x x} \propto e^{\lambda_{\pm}^{\mathrm{BLG}} y} e^{ik_x x},$$

$$\lambda_{\pm}^{\mathrm{BLG}} = \frac{1}{v} \sqrt{v^2 k_x^2 - \varepsilon^2 - \frac{\Delta^2}{4} \pm \sqrt{\Delta^2 \varepsilon^2 - \gamma_1^2 \left(\frac{\Delta^2}{4} - \varepsilon^2\right)}}.$$
(8)

Substituting these in Eq. (4a) for  $y \le 0$ , we find that

$$\psi^{\text{BLG}}(k_{x},\varepsilon) = B_{+} \begin{pmatrix} \alpha_{+} \\ \beta_{+} \\ \chi_{+} \\ 1 \end{pmatrix} e^{\lambda_{+}^{\text{BLG}}y} + B_{-} \begin{pmatrix} \alpha_{-} \\ \beta_{-} \\ \chi_{-} \\ 1 \end{pmatrix} e^{\lambda_{-}^{\text{BLG}}y}, \quad \alpha_{\pm} = \frac{-2\gamma_{1}(\Delta + 2\varepsilon)(\Delta - 2\varepsilon)}{X_{\pm}},$$

$$\beta_{\pm} = \frac{4\gamma_{1}v(k_{x} + \lambda_{\pm}^{\text{BLG}})(\Delta + 2\varepsilon)}{X_{\pm}}, \quad \chi_{\pm} = \frac{(\Delta + 2\varepsilon)\left[(\Delta - 2\varepsilon)^{2} - 4v^{2}(k_{x}^{2} - (\lambda_{\pm}^{\text{BLG}})^{2})\right]}{X_{\pm}},$$

$$X_{\pm} = 2v(k_{x} - \lambda_{\pm}^{\text{BLG}})\left\{(\Delta - 2\varepsilon)^{2} - 4v^{2}[k_{x}^{2} - (\lambda_{\pm}^{\text{BLG}})^{2}]\right\}. \tag{9}$$

Requiring continuity of the eigenstates at the BLG-2ML interface, we find

$$\begin{pmatrix}
-1 & 0 \\
-a_{-\xi_{+},+} & 0 \\
0 & -1 \\
0 & -a_{-\xi_{-},-}
\end{pmatrix}
\begin{pmatrix}
A_{-\xi_{+},+} \\
A_{-\xi_{-},-}
\end{pmatrix} = \begin{pmatrix}
1 & 0 & -\alpha_{+} & -\alpha_{-} \\
a_{+\xi_{+},+} & 0 & -\beta_{+} & -\beta_{-} \\
0 & 1 & -\chi_{+} & -\chi_{-} \\
0 & a_{+\xi_{-},-} & -1 & -1
\end{pmatrix}
\begin{pmatrix}
A_{+\xi_{+},+} \\
A_{+\xi_{-},-} \\
B_{+} \\
B_{-}
\end{pmatrix}, (10)$$

which is nothing but the conservation condition for the current projected onto the direction perpendicular to the boundary.

Fixing the incoming wave to reside solely on the upper monolayer  $(A_{-\xi_+,+} = 1 \text{ and } A_{-\xi_-,-} = 0)$ , we investigate how the electrons can relocate from it to the lower layer, with the amplitude of the interlayer transfer given by

$$A_{+\xi_{-},-} = \frac{(a_{\xi_{+},+} - a_{-\xi_{+},+})(\chi_{+} - \chi_{-})}{(a_{+\xi_{+},+}\alpha_{+} - \beta_{+})(1 - a_{+\xi_{-},-}\chi_{-}) - (a_{+\xi_{+},+}\alpha_{-} - \beta_{-})(1 - a_{+\xi_{-},-}\chi_{+})} \xrightarrow[k_{y} < k_{x}, \delta]{k_{y}} \xrightarrow[k_{y} < k_{x}, \delta]{k_{y}}.$$
(11)

In the limit where momentum parallel to the interface and the monolayer on-site energy asymmetry are large,  $k_y \ll k_x$ ,  $\delta$ , this indicates that the probability of an electron changing layer is small. In Fig. 2(a) we show how the probability of reflection back on the same layer,

$$P = \frac{|A_{+\xi_{+},+}|^2}{|A_{+\xi_{+},+}|^2 + |A_{+\xi_{-},-}|^2},\tag{12}$$

varies with wave vector  $k_x$  as we move around the Dirac cone at three separate energy cuts for  $\delta = U = 0$ . In agreement with Eq. (11), we find that for  $|k_y| \ll |k_x|$  the probability of reflection back to the same layer approaches P=1 (that is,  $A_{+\xi_{-},-} \ll 1$  is also associated with a  $\pi$  phase shift of the reflected wave), whereas peak transmission,  $P \approx 0.5$ , onto the second layer occurs for waves incident at angle  $\pi/3$ .

### **B.** Evanescent interface states

In addition to scattered waves, a BLG-2ML interface supports evanescent modes over the entire energy range  $|\varepsilon| < \varepsilon_*$ . These are described by Eq. (9) in the BLG region and by Eq. (6) in the 2ML delamination, but now with  $q_{s,l} = -i\lambda_{s,l}^{2\text{ML}}$ , where

$$\lambda_{s,l}^{\text{2ML}} = s \frac{1}{v} \sqrt{v^2 k_x^2 - \left(\varepsilon - U - l \frac{\delta}{2}\right)^2}$$
 (13)

are real-valued decay rates. Continuity of these evanescent wave functions across the interface (selecting, e.g., s = -1)

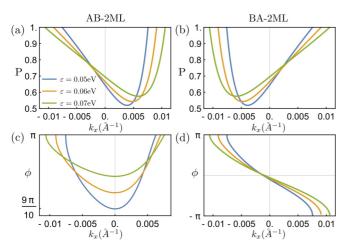


FIG. 2. (a) Probability of reflection back on the same (upper) layer as the incoming wave for AB stacking within the bilayers. (b) Results for the opposite BLG stacking (BA) which exhibits identical reflection probability dependence under transformation  $k_x \rightarrow -k_x$ . (c) and (d) Phase  $\phi$  acquired upon reflection back on the same layer corresponding to (a) and (b).

produces the matching condition,

$$\begin{pmatrix}
\alpha_{+} & \alpha_{-} & -1 & 0 \\
\beta_{+} & \beta_{-} & -a_{-,+} & 0 \\
\chi_{+} & \chi_{-} & 0 & -1 \\
1 & 1 & 0 & -a_{-,-}
\end{pmatrix}
\begin{pmatrix}
B_{+} \\
B_{-} \\
A_{-,+} \\
A_{-,-}
\end{pmatrix} = 0. (14)$$

To find its solution, we have to require that

$$\det \mathcal{D}(\varepsilon, k_x) = 0,$$

which sets the dispersion relation  $\varepsilon(k_x)$  for the evanescent modes. Figure 3 shows the results of solving numerically for these one-dimensional states localized near the BLG-2ML interface for  $\Delta=0.2$  eV and  $\delta=0$ . Having noticed an almost linear dispersion of such states, we also find that the dispersion of evanescent modes is almost linear for arbitrary values of all electrostatically controlled parameters in our theory, assuming

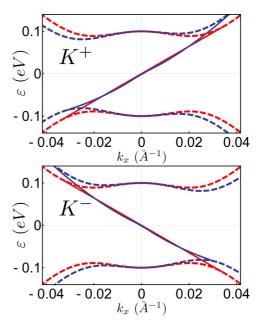


FIG. 3. Interface states (solid red curves) and low energy BLG bands (dashed red curves) at y=0 for  $\Delta=0.2\,\mathrm{eV}$  and  $\delta=U=0$  in the  $K^+$  (top) and  $K^-$  (bottom) valley. Blue curves depict the bands for nonzero skew interlayer coupling,  $\gamma_3$ , for a delamination along the zig-zag direction, illustrating the negligible effect that this additional hopping term has on the spectrum at a delamination edge.

that  $vk_x, \Delta, \delta, U \ll \gamma_1$ ,

$$\varepsilon \approx \eta \sqrt{\frac{\Delta}{\gamma_1}} v k_x,$$
 (15)

and modes in the opposite valleys,  $\eta = \pm$ , propagate in opposite directions. Exchanging the interlayer stacking configuration in the bilayer region (AB  $\rightarrow$  BA) or swapping the ordering of the two regions (2ML on the left and BLG on the right) results in mirror-reflected dispersions equivalent to those illustrated in Fig. 3.

# III. ELECTRONIC SPECTRUM OF A DELAMINATION IN BLG

Here, we analyze the electronic spectrum of a delamination (2LG) between two bilayer regions to the left ( $y \le 0$ ) and right  $(y \ge W)$  sides (see Fig. 1) for the same (AB-2ML-AB) and opposite (AB-2ML-BA) stacking on the two sides.

# A. AB-2ML-BA stacking

Depending on the fabrication process generating the delamination, the layers in a BLG may be shifted from one Bernal stacking configuration to another, producing the inverted (BA vs AB) stacking on the opposite side of the delamination. The resulting deformation, of the order of one lattice constant of graphene (a = 1.42 Å), is then absorbed by a weak strain/shear of the delaminated monolayers. The effect of homogeneous weak strain over a narrow stripe of the upper/lower monolayer in the 2ML part of the structure consists of an addition of a vector potential term to the Dirac equation in the monolayers [22], producing small shifts in the wave numbers and energies of modes guided by the delamination. In the following, we neglect these small ( $\sim a/W$ ) shifts and focus on the qualitative change in the delamination spectrum brought about by the stacking order: its gapless character.

The continuous model for the system with AB-2ML-BA stacking, written in the basis  $(A_1, B_1, B_2, A_2)^T$ , is described by the Hamiltonian

$$\hat{\mathcal{H}}_{\eta} = \begin{pmatrix} V_{+}(y) & v\hat{\pi}^{\dagger} & \Theta(-y)\gamma_{1} & 0\\ v\hat{\pi} & V_{+}(y) & 0 & \Theta(y-W)\gamma_{1}\\ \Theta(-y)\gamma_{1} & 0 & V_{-}(y) & v\hat{\pi}\\ 0 & \Theta(y-W)\gamma_{1} & v\hat{\pi}^{\dagger} & V_{-}(y) \end{pmatrix}, \tag{16}$$

where on-site energies on the upper (+) and lower (-) layers are

$$V_{\pm}(y) = \begin{cases} \pm \frac{\Delta}{2} & \text{if } y \leqslant 0 \text{ or } y \geqslant W, \\ U \pm \frac{\delta}{2} & \text{if } 0 < y < W. \end{cases}$$
 (17)

For y < 0 and 0 < y < W, the wave functions retain the form given in Eqs. (6) and (9), whereas for y > W (BA stacked BLG) parameters in  $\psi^{\text{BLG}}$  in Eq. (9) should be substituted with

$$\tilde{\alpha}_{\pm} = \frac{4\gamma_{1}v(\Delta + 2\varepsilon)(k_{x} - \lambda_{\pm}^{BLG})}{X_{\pm}}$$

$$\tilde{\beta}_{\pm} = -\frac{2\gamma_{1}(\Delta + 2\varepsilon)(\Delta - 2\varepsilon)}{X_{\pm}}$$

$$\tilde{\chi}_{\pm} = \frac{2v(k_{x} + \lambda_{\pm}^{BLG})\left[(\Delta - 2\varepsilon)^{2} - 4v^{2}\left(k_{x}^{2} - (\lambda_{\pm}^{BLG})^{2}\right)\right]}{X_{\pm}},$$

$$\tilde{X}_{\pm} = (\Delta + 2\varepsilon)\left[(\Delta - 2\varepsilon)^{2} - 4v^{2}\left(k_{x}^{2} - (\lambda_{\pm}^{BLG})^{2}\right)\right].$$
(18)

Wave-matching conditions applied at both interfaces,  $\psi(y \to 0^-) = \psi(y \to 0^+)$  and  $\psi(y \to W^-) = \psi(y \to W^+)$ , result in

$$\frac{\begin{pmatrix} \alpha_{+} & \alpha_{-} & 1 & 1 & 0 & 0 & 0 & 0 \\ \beta_{+} & \beta_{-} & a_{+,+} & a_{-,+} & 0 & 0 & 0 & 0 \\ \lambda_{+} & \lambda_{-} & 0 & 0 & 1 & 1 & 0 & 0 \\ 1 & 1 & 0 & 0 & a_{+,-} & a_{-,-} & 0 & 0 & 0 \\ 0 & 0 & e^{\lambda_{+,+}^{MLG}W} & e^{\lambda_{-,+}^{MLG}W} & 0 & 0 & \tilde{\alpha}_{+}e^{-\lambda_{+}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & a_{+,+}e^{\lambda_{+,+}^{MLG}W} & a_{-,+}e^{\lambda_{-,-}^{MLG}W} & 0 & 0 & \tilde{\beta}_{+}e^{-\lambda_{+}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & 0 & 0 & 0 & e^{\lambda_{+,-}^{MLG}W} & e^{\lambda_{-,-}^{MLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & 0 & 0 & 0 & e^{\lambda_{+,-}^{MLG}W} & e^{\lambda_{-,-}^{MLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & 0 & 0 & e^{\lambda_{+,-}^{MLG}W} & e^{\lambda_{-,-}^{MLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & 0 & 0 & e^{\lambda_{+,-}^{MLG}W} & e^{\lambda_{-,-}^{MLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ 0 & 0 & 0 & 0 & e^{\lambda_{+,-}^{MLG}W} & e^{\lambda_{-,-}^{MLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} & \tilde{\alpha}_{-}e^{-\lambda_{-}^{BLG}W} \\ \tilde{\beta}_{-} & \tilde{\beta}_{-} \\ \tilde{\beta}_{-} & \tilde{\beta}_{-} \\ \tilde{\beta}_{-} & \tilde{\beta}_{-} &$$

As with the single-interface system, we require that

$$\det \tilde{\mathcal{D}}(\varepsilon, k_x) = 0.$$

Solving this equation numerically, we generate the dispersion curves  $\varepsilon(k_x)$  shown in Fig. 4, which represent the main features of the delamination spectra.

Figure 4 illustrates the bands [Figs. 4(e)-4(h)] and wave functions [Figs. 4(a)-4(d)] for a range of monolayer band offsets, calculated from the continuum model. These plots show the spectra for electrons in valley  $K^+$ . Dispersions in valley  $K^-$  can be obtained using the time reversal,  $\varepsilon(K^-,k_x) =$  $\varepsilon(K^+, -k_x)$ . Wave functions for the interface states are displayed in Figs. 4(a) and 4(c), which demonstrate localization of these valley-polarized modes at both interfaces. Note that although an increasing number of bands becomes available as we open up the 2ML gap  $\delta$ , there are only these two interface states which span the entire region. Therefore, tuning the Fermi level of the system such that it lies close to zero will select states corresponding to one-dimensional ballistic channels propagating simultaneously along each interface. The gap  $\varepsilon_g$  between the lowest "conduction" and "valence" bands is shown to decrease as  $\varepsilon_g \propto W^{-1}$  with delamination width (see the Appendix).

We also employ a numerical TB approach by modeling the considered structure as a semi-infinite zigzag BLG nanoribbon of lattice sites with a delaminated region separating two BLG regions with opposite stacking. We incorporate a mismatch of one carbon-carbon bond length into the widths of the layers in the 2ML region [23]. Modifying the standard TB Hamiltonian for BLG to include the desired structure produces

$$\hat{\mathcal{H}} = -\sum_{l} \sum_{\langle i,j \rangle} (\gamma_0 c_{l,i}^{\dagger} c_{l,j})$$

$$-\sum_{\langle i \rangle} \{ [\Theta(-y_i) + \Theta(y_i - W)] \gamma_1 c_{1,i}^{\dagger} c_{2,i} + \text{H.c.} \}$$

$$+ \sum_{i} V_{\pm}(y_i) c_i^{\dagger} c_i, \qquad (20)$$

with  $\gamma_0=3.1$  being the intralayer nearest-neighbor coupling,  $\gamma_1=0.39$  eV being the interlayer nearest-neighbor coupling, and  $c_{l,i}^{\dagger}$  ( $c_{l,i}$ ) being the creation (annihilation) operator for electrons at site  $\vec{R}_i=(x_i,y_i)$  in layer l. On-site potentials  $V_+(y_i)$  [ $V_-(y_i)$ ] on the upper (lower) layer are given by Eq. (17). The sum in the first line runs over all nearest neighbors  $\langle i,j\rangle$ , the second line runs over all the coupled dimer sites  $\langle i\rangle$ , and the final term sums over all lattice sites i. The difference between the AB and BA regions is taken into account as a change of the dimer sites, meaning that the coupling is present between sites  $A_1$ - $B_2$  [ $\Theta(-y_i)$ ] and  $B_1$ - $A_2$  [ $\Theta(y_i-W)$ ], respectively.

For numerical diagonalization, we used 2000 Å for the total width of the AB-2ML-BA nanoribbon along the *y* axis and zigzag edges. To prevent states localized along these terminating edges [20,24,25] from obscuring the states in the delaminated region, we apply a large positive (negative) on-site potential on the edge atoms which pushes these states to higher (lower) energies.

Using TB Hamiltonian (20), we find the spectrum of states guided by the delamination by solving the equation  $[\hat{\mathcal{H}}(k_x) - \varepsilon(k_x)\hat{\mathcal{I}}]\Psi = 0$  for different values of wave vector  $k_x$ . Additionally, using the Kernel Polynomial Method (KPM)

method [26] implemented in the PYBINDING package [27], we investigate the density of states (DOS) and local DOS (LDOS).

The spectra found using the TB approach are shown in Figs. 4(i)–4(k) for the same parameters as in continuum theory [Figs. 4(f)–4(h)] [28]. As with the AB-2ML-AB system, the delamination exhibits both localized channels along the interface and standing-wave modes across the delaminated monolayers, but the interface states now span the full range of the BLG gap [identified in red in Figs. 4(e)–4(k)]. Note that the spectra obtained with the two methods coincide in all details, including all avoided and nonavoided crossings between interface states and standing-wave states. Also confirmed by both calculation methods is that the change in stacking order breaks the  $\varepsilon(k_x) = \varepsilon(-k_x)$  symmetry for the states in one valley and that  $\varepsilon_{K+}(k_x) = \varepsilon_{K-}(-k_x)$ .

#### B. AB-2ML-AB stacking

Having established a good agreement between the properties of ballistic electron channels evaluated using the TB approach and wave matching, we study a delamination with the same stacking in the outer BLG regions using only the continuous theory, with the Hamiltonian

$$\hat{\mathcal{H}}_{\eta} = \begin{pmatrix} V_{+}(y) & v\hat{\pi}^{\dagger} & \Phi \gamma_{1} & 0 \\ v\hat{\pi} & V_{+}(y) & 0 & 0 \\ \Phi \gamma_{1} & 0 & V_{-}(y) & v\hat{\pi} \\ 0 & 0 & v\hat{\pi}^{\dagger} & V_{-}(y) \end{pmatrix}. \tag{21}$$

Here,  $\Phi = \Theta(-y) + \Theta(y-W)$  and  $V_{\pm}(y)$  take the same values as in Eq. (17). Electron states for 0 < y < W are described by Eq. (6), where wave vectors  $q_{s,l}$  may take both real and imaginary values. For energies  $|\varepsilon| < \varepsilon_*$ , states in the left bilayer remain evanescent, Eq. (9), with states in the right bilayer obtained by the substitution  $y \to W - y$ .

Matching these wave functions at the two interfaces, we recover Eq. (19), where  $\alpha_{\pm}$ ,  $\beta_{\pm}$ , and  $\chi_{\pm}$  are defined in Eq. (9) and  $\tilde{\alpha}_{\pm} = \alpha_{\pm}(-\lambda_{\pm}^{BLG})$ ,  $\tilde{\beta}_{\pm} = \beta_{\pm}(-\lambda_{\pm}^{BLG})$ , and  $\tilde{\chi}_{\pm} = \chi_{\pm}(-\lambda_{\pm}^{BLG})$  such that the same AB-stacked BLG states decay to the right of the delamination. As with the AB-2ML-BA system we require that det  $\tilde{\mathcal{D}} = 0$ , producing dispersions across the delamination shown in Fig. 5.

These spectra are formed by the hybridization of evanescent modes coming from the opposite edges of the delamination and standing waves bouncing between the edges. For wider delaminations or larger  $\delta$ , we find more subbands that can fit the BLG asymmetry gap. Higher subbands correspond to bouncing modes within the monolayers. Note that the spectra shown in Fig. 5 are gapped. As with the AB-2ML-BA system, the values of energy gaps between bands exhibit  $\varepsilon_g \propto (W+W_0)^{-1}$  dependence with delamination width (see the Appendix).

The gaps in the delamination spectrum also depend on the interlayer asymmetry  $\delta$ , which is controlled by the displacement field  $E_z$ . Wave functions in Figs. 6(i)–6(l) demonstrate that, for large  $\delta$ , electronic states just above and below the avoided crossings are localized on different delaminated monolayers. The crossing occurs at momentum  $k_x \approx \delta/2v$ , and the standing-wave states within the delamination have  $k_y = \pi/W \ll \delta/2v$ . Using Eq. (11) for the interlayer transmission

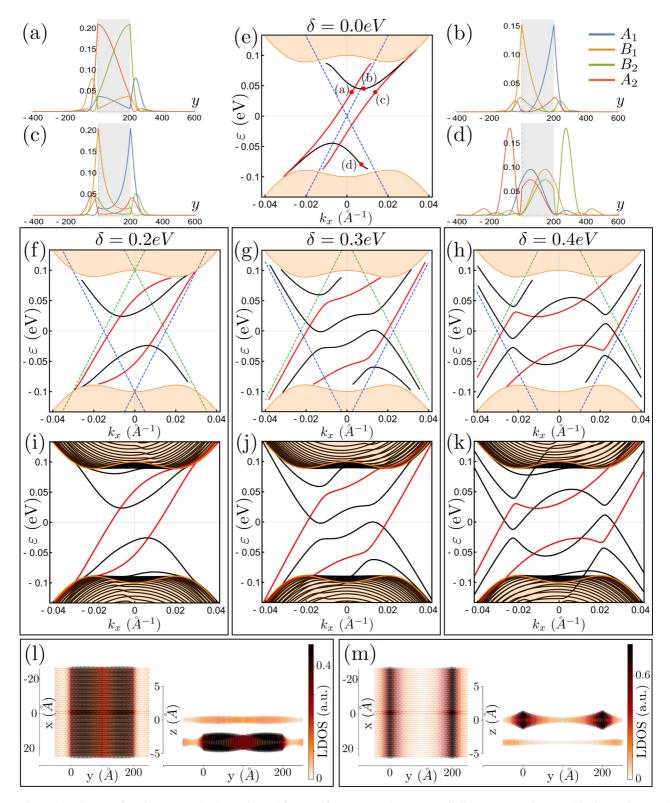


FIG. 4. (a)–(d) Wave function across the 2ML channel for specific energy and momenta [indicated on (e)] in the sublattice basis. (e)–(h) Permitted energy bands calculated from the continuum model within the bilayer gap and (i)–(k) the results of an equivalent TB calculation approach including continuum bands which extend above the bilayer band edge. Interface modes (red curves) are identified crossing between the low-energy bilayer band edges (orange shaded regions). Plotted with green (blue) dashed lines are the conical dispersions of the upper (lower) monolayer with energy difference  $\delta$  between their Dirac points. (l) and (m) Top and side profiles of the LDOS for the same parameters as in (c) and (d). Calculations were performed for W=200~Å,  $\Delta=0.2~\text{eV}$ , and U=0 around the  $K^+$  valley.

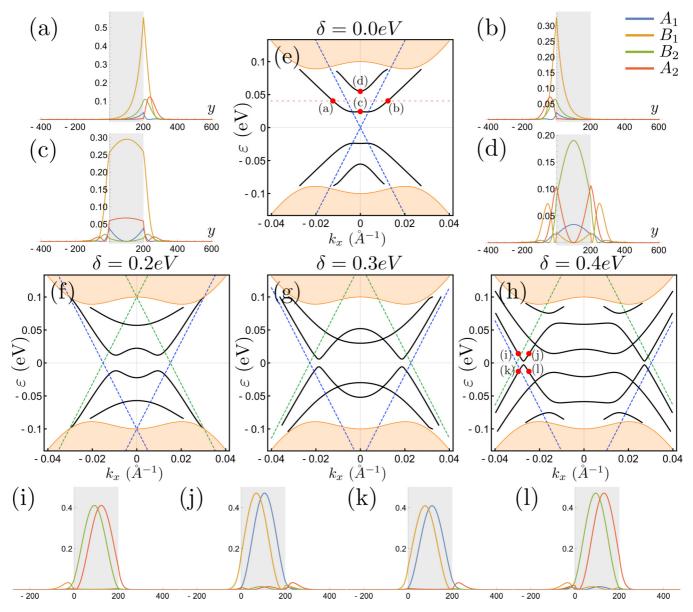


FIG. 5. (a)–(d) and (i)–(l) Electron wave functions across the delamination (gray shaded region) for specific energy and momenta indicated in (e) and (h) in sublattice basis  $(A_1, B_1, B_2, A_2)^T$ . (e)–(h) Energy structure of the delamination for increasing interlayer energy gap  $\delta$  within the monolayer region. Green (blue) dashed lines denote the upper (lower) monolayer Dirac cones in the 2ML region, and the orange region denotes the low-energy bulk bilayer band edge. Calculations are for W = 200 Å,  $\Delta = 0.2 \text{ eV}$ , and U = 0 around the  $K^+$  valley.

amplitude, we estimate for the size of the gap

$$\varepsilon_g \propto |A_{+\xi_-,-}| \approx \frac{2v\pi/W}{\delta},$$
 (22)

which is in agreement with our numerical data.

Additionally, we studied how an offset U between the BLG and 2ML regions affects the energy dispersions of both the AB-2ML-AB and AB-2ML-BA structures. Figure 6 depicts this for two different offsets in both the AB-2ML-AB and AB-2ML-BA interlayer stackings: in Figs. 6(a)–6(d) are bands calculated using the continuum model, and in Figs. 6(e) and 6(f) are bands found using the TB model in the form of the DOS maps. Figure 6 shows that an increase in either U or  $\delta$  (or both) brings more subbands into the delamination spectrum inside the BLG gap.

# IV. DELAMINATION SPECTRUM IN A PERPENDICULAR MAGNETIC FIELD

To investigate the effects of a perpendicular magnetic field on the interface states, we use the TB model and apply a Peierls substitution to the in-plane coupling terms in Eq. (20),

$$\hat{\mathcal{H}} = -\sum_{l} \sum_{\langle i,j \rangle} (\gamma_0 e^{i2\pi \Phi_{ij}/\Phi_0} c_{l,i}^{\dagger} c_{l,j})$$

$$-\sum_{\langle i \rangle} \{ [\Theta(y_i) + \Xi(y_i)] \gamma_1 c_{1,i}^{\dagger} c_{2,j} + \text{H.c.} \}$$

$$+\sum_{i} V_{\pm}(y_i) c_i^{\dagger} c_i. \tag{23}$$

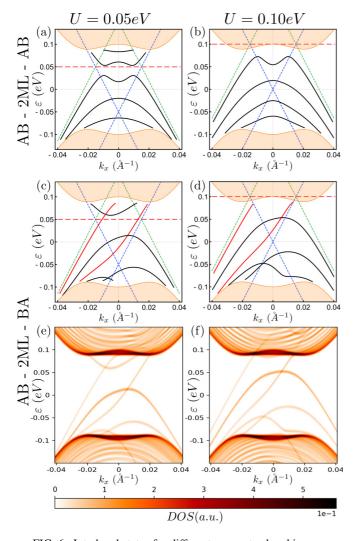


FIG. 6. Interband states for different symmetry-breaking energy of-sets U for both (a) and (b) AB-2ML-AB and (c)–(f) AB-2ML-BA stacking with W=200 Å and  $\Delta=\delta=0.2$  eV. In (a)–(d), calculated using the continuum model, the red dashed line indicates the 2ML region energy midpoint, and green and blue dashed lines indicate the positions of the bulk 2ML Dirac cones. (e) and (f) Density of states of the system calculated from the TB model.

Here,  $\Phi_0 = \frac{h}{e}$  is the magnetic flux quantum, and  $\Phi_{ij} = \int \vec{A} dl$  is the flux accumulated between atomic sites i and j due to the external magnetic field. Using the Landau gauge,  $\vec{A} = By\hat{x}$ , we find  $\Phi_{ij} = 0.5B(y_j + y_i)(x_j - x_i)$ .

Figures 7(a)–7(d) show that a perpendicular magnetic field increases [18] the visibility of the interface states. The wave functions of the standing wave states are delocalized over the relatively wide delaminated region and therefore readily form Landau levels when the radius of the cyclotron orbit of monolayer graphene drops below half the delamination width  $(r_0 \sim l_B = \sqrt{\hbar/eB} < W/2)$ . For a W = 200 Å structure [Figs. 7(a)–7(d)], this corresponds to a magnetic field of  $B \approx 7$  T and results in the energies of these states being pushed out of the energy range of the band gap in bilayer graphene. In contrast, the interface states are less susceptible to Landau-level formation as their unidirectional propagation and

confinement near the edges inhibit the formation of cyclotron orbits. Nevertheless, as the magnetic field strength increases from 0 to 30 T, a clear precursor to a zeroth Landau level is seen in the flattening of the dispersions near  $k_x = \epsilon = 0$  and a concomitant localization of the wave function in the center of the delaminated region [compare Figs. 7(a)-7(c) and 7(e)-7(g)]. Similar flattening of the interface bands is found for a finite interlayer shift near  $k_x = 0$ ,  $\epsilon = \pm 0.045$  eV [e.g., yellow dot, Fig. 7(d)]. The energies of these features are well approximated by the first Landau-level energy counted from the Dirac cone in the appropriate layer,  $\epsilon = \pm (v\sqrt{2}/l_B - \delta/2) = 0.041$  eV, and the corresponding wave function [Fig. 7(h)] displays characteristics of the first graphene Landau level.

For energies away from these band flattenings [e.g., red dots in Figs. 7(b)–7(d)] the wave function is found to be pushed towards the left interface [Figs. 7(j)–7(l)], rather than in the center of the delamination, as is found for the Landau-level-like features in Figs. 7(f)–7(h). This behavior can be interpreted as the result of a Lorentz force,  $e\vec{v} \times \vec{B}$ , for an electron with velocity in the x direction. As the velocity of the interface states is reversed for the other  $(K^-)$  valley, the corresponding states there are pushed towards the opposite edge. This produces a spatial separation of the wave functions in the two valleys and, consequently, an enhanced robustness of these states against intervalley scattering disorder [12].

### V. DISCUSSION

In this paper we have studied the electronic properties of delaminations in bilayer graphene with a gate-induced band gap. Starting with a single boundary between a bilayer graphene region and two decoupled monolayer graphene sheets, we have shown that there exist evanescent states localized at the interface which span the bilayer energy gap and have opposite carrier velocity in each of graphene's two valleys. In a delamination stripe with opposite stacking of the outer BLG, these evanescent states give rise to the gapless channels counterpropagating in opposite valleys. The delaminations, with both AB-2ML-BA and AB-2ML-AB stacking, also support channels produced by bouncing modes in the two delaminated monolayers. The number of such modes increases with delamination width W, as well as with the transverse electric field  $E_z$ , which controls the difference,  $\delta = eE_zd'$ , between on-layer electron energies in the delamination.

The above results have been obtained for the delamination with an almost arbitrary crystallographic direction, except for the orientation where the delamination edge exactly coincides with the armchair direction in graphene. In the latter case, the armchair edge mixes states in graphene's two valleys, and the spectrum of an AB-2ML-BA delamination, obtained by TB model calculation and shown in Fig. 8, has modes inside the BLG gap which are not protected against anticrossing by the valley structure of electron states. Such states seem to retain linear dispersion similar to the case of a generic orientation of delamination edges.

Another point to mention is related to the role of  $\gamma_3$  hopping terms in the TB model, which were neglected in modeling the electronic spectra. Those terms produce [3] only weak trigonal warping effects in BLG and can be neglected but also (together with the variation of  $\gamma_1$  coupling along the

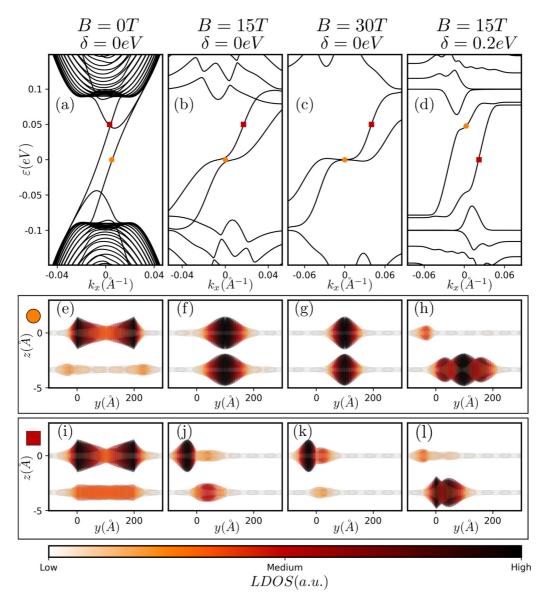


FIG. 7. (a)–(d) Band structure and (e)–(l) LDOS maps at specific values of energy and wave vector for the nanoribbon in the presence of a perpendicular magnetic field. (e–h) and (i–l) depict the distribution of the states at the value of  $\varepsilon$  and  $k_x$  marked on the band structure plots with yellow circles and red squares, respectively. Calculations are for W = 200 Å,  $\Delta = 0.2 \text{ eV}$ , and U = 0 in the vicinity of the  $K^+$  valley.

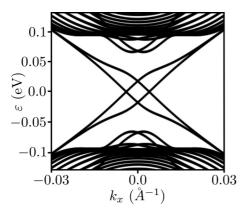


FIG. 8. Energy dispersion for an AB-2ML-BA delamination with armchair edges, calculated using the TB model for  $\Delta=0.2$  eV,  $\delta=U=0$ , and W=200 Å.

delamination edge) may generate a source of scattering at the exact delamination edge with arbitrary (different from exact zigzag) orientation. The analysis of such disorder will be a subject for a separate study.

# ACKNOWLEDGMENTS

This work was funded by EPSRC via EPSRC Grand Engineering Chellenges Grant No. EP/N010345, the Manchester NOWNANO CDT EP/L-1548X, the Flemish Science Foundation (FWO-VI), the European Graphene Flagship project, ERC Synergy grant Hetero2D, and FLAG-ERA project TRANS2DTMD. The authors would like to acknowledge useful discussions with M. Zarenia, S. Slizovskiy, E. McCann, and K. Novesolov.

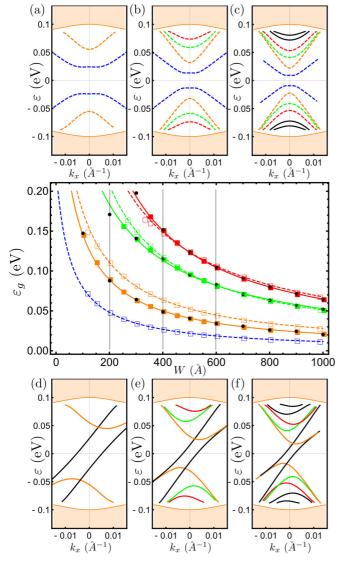


FIG. 9. Dependence of energy gaps on delamination width. Open squares and dashed curves show data and fitting for the AB-2ML-AB system, respectively, while solid squares and solid curves show data for the AB-2ML-BA system. Black points represent data extracted from the TB model for the AB-2ML-BA system. (a)–(c) Band structures at W=200 Å, W=400 Å, and W=600 Å, respectively for the AB-2ML-AB system. (d)–(f) Band structures at W=200 Å, W=400 Å, and W=600 Å, respectively, for the AB-2ML-BA system. Plots are calculated for  $\Delta=0.2$  eV and  $\delta=U=0$  around the  $K^+$  valley.

TABLE I. Fitting parameters for curves in Fig. 9.

Curve	a	b
Dashed blue	12.2	53.6
Dashed orange	30.1	72.3
Dashed green	54.2	61.2
Dashed red	74.5	102.5
Solid orange	22.7	55.9
Solid green	59.2	123.1
Solid red	68.2	52.7

### APPENDIX: ENERGY GAPS IN DELAMINATED SYSTEMS

The number of available states within the BLG gap and their corresponding energies is highly sensitive, not only to the electrostatic parameters (as demonstrated in Figs. 4 and 5) but also to the width of the stacked monolayer channel. Decreasing the width *W* of the delamination opens up larger energy gaps between subsequent bands and pushes them out of our energy range of interest.

Figure 9 illustrates how the energy gaps of the band minima vary with increasing delamination width for both AB-2ML-AB and AB-2ML-BA interlayer stacking, calculated assuming  $\delta = 0$  for simplicity (although this is not experimentally viable). Fittings are of the form

$$\varepsilon_g = a(W+b)^{-1},\tag{A1}$$

with fitting parameters given in Table I. Dashed curves are fit to data from systems with the same interlayer stacking in each bilayer (open squares), while solid lines are fit to data from systems with different interlayer stackings to either side of the delamination (solid squares). Black circles show data from the AB-2ML-BA TB model to be in good agreement with the corresponding wave-matching model.

The lowest-energy (dashed blue) curve corresponds to minima arising from avoided crossings of counterpropagating evanescent states localized at each interface in the AB-2ML-AB system. There is no complementary curve for the AB-2ML-BA system since the localized channels for this configuration are copropagating and the resulting low-energy bands span the entire gap. The energy gap between higher-energy bands follows the same general form, with especially close agreement between green and red curves in each system.

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